Active and Passive Elec. Comp., 1994, Vol. 16, pp. 105–107 Reprints available directly from the publisher Photocopying permitted by license only © 1994 Gordon and Breach Science Publishers S.A. Printed in Malaysia

EVALUATION OF BONDING ORBITALS IN AMORPHOUS SILICON BY MEANS OF THE CHEMICAL PSEUDOPOTENTIAL METHOD

M.A. GRADO CAFFARO, consultant (Madrid, Spain) and M. GRADO CAFFARO, consultant (Madrid, Spain)

C./Julio Palacios, 11, 9^oB, 28029—Madrid (Spain) (Received August 12, 1993; in final form September 10, 1993)

The chemical pseudopotential method has been used by a number of workers in order to study the valence bands of amorphous tetrahedrally bonded semiconductors. However, various problems related to this method are unsolved. In this paper, a theoretical formulation tending to clarify some of these problems is presented.

This formulation concerns bonding orbitals and is valid, in principle, for amorphous silicon.

I. INTRODUCTION

Localised pseudopotential theory is applicable to evaluate localised orbitals in amorphous semiconductors. This theory was applied by P.W. Anderson^{1,2} in order to calculate localised orbitals for use in solid-state chemical bonding problems. In addition, other workers have studied bonding problems in the context of amorphous semiconductors.³

The chemical pseudopotential method is related to certain empirical and semiempirical techniques as, for example, the empirical pseudopotential method (EPM). In certain cases, EPM has provided results in good agreement with experimental results. This method, as well as other similar methods, have been used to analyze complex systems.⁴⁻⁷

In the following, we shall use a method that offers a high level of reliability. By considering bonding orbitals, we shall establish an interesting equation for the electronic density of states corresponding to amorphous silicon. In fact, our theoretical formulation involves the determination of the electronic density of states in a unique way.

II. THEORETICAL FORMULATION

First, let us consider two isolated atoms 1 and 2. We can write:

 $\mathbf{H}_{12}|\boldsymbol{\phi}_{12}\rangle = \mathbf{E}|\boldsymbol{\phi}_{12}\rangle$

(1)

Where H_{12} denotes hamiltonian, E means energy, and $|\phi_{12}\rangle$ is local bonding orbital. A given electron in the bonding orbital is influenced by the potential of perturbation of the above atoms. This potential satisfies the following relation:

$$V_{12} = H - H_{12}$$
(2)

where V_{12} is the potential and H is the total single-electron hamiltonian.

We shall formulate the potential by using the Born model. Then, we have:⁸

$$V_{12} = \frac{3}{2} \beta [(\vec{u}_1 - \vec{u}_2) \cdot \hat{r}_{12}]^2 + \frac{1}{2} (\alpha - \beta) |\vec{u}_1 - \vec{u}_2|^2$$
(3)

where \vec{u}_1 and \vec{u}_2 are the displacement vectors of the atoms 1 and 2 respectively, and \hat{r}_{12} stands for a unit vector that connects the atoms. The parameters α and β are force constants.

On the other hand, we choose $\alpha = 2\beta$ and we consider $\vec{u}_1 \cdot \hat{r}_{12} = \vec{u}_2 \cdot \hat{r}_{12}$ (see ref. [9]). Then, from eq. (3) it is obtained:

$$\mathbf{V}_{12} = \frac{1}{2} \,\boldsymbol{\beta} |\vec{\mathbf{u}}_1 - \vec{\mathbf{u}}_2|^2 \tag{4}$$

By combining eqs. (1), (2) and (4), we have:

$$2\mathbf{H}|\phi_{12}\rangle - \beta|\mathbf{\tilde{u}}_1 - \mathbf{\tilde{u}}_2|^2|\phi_{12}\rangle = 2\mathbf{E}|\phi_{12}\rangle \tag{5}$$

Moreover, the molecular orbital in eq. (5) can be expressed as follows:³

$$|\phi_{12}\rangle = c(|\phi_{1\rightarrow 2}\rangle + |\phi_{2\rightarrow 1}\rangle) \tag{6}$$

where c is a constant, $|\phi_{1\to 2}\rangle$ is the orbital on atom 1 directed towards atom 2, and $|\phi_{2\to 1}\rangle$ is the orbital on atom 2 directed towards atom 1. Eq. (6) represents the normalized sum of a Pauling-type hybridised sp³ orbital on each atom.

Finally, we will consider the local electronic density of states namely:¹⁰

$$g(\vec{r}, E) = \sum_{n} \left[\left| \int_{R'} \psi_{n}(\vec{r}') \phi_{12}(\vec{r}' - \vec{r}) d\vec{r}' \right|^{2} \delta(E - E_{n}) \right]$$
(7)

where ψ_n denotes eigenfunction that satisfies:³

$$\mathbf{H}|\psi_{n}\rangle = \mathbf{E}_{n}|\psi_{n}\rangle \tag{8}$$

In eq. (8) E_n is the energy eigenvalue corresponding to ψ_n . By determining ψ_n from eq. (8), it is feasible to use eq. (7) by also taking into consideration eqs. (5) and (6). Furthermore, for very small clusters of atoms, we can use the following approximation to obtain the total density of states, namely:¹¹

$$g(E) \approx \Omega g(\vec{o}, E)$$
 (9)

where Ω is the volume of the cluster and $g(\vec{o}, E)$ arises from eq. (7) so that:

$$g(E) \approx \Omega \sum_{n} \left[\left| \int_{R'} \psi_{n}(\vec{r}\,') \phi_{12}(\vec{r}\,') \, d\vec{r}\,' \right|^{2} \delta(E - E_{n}) \right]$$
(10)

III. DISCUSSION

We have established a chain of equations whose end is the total electronic density of states for amorphous silicon. This total density arises from the local density of states. All equations exposed here are important; in particular, eq. (8) is the Schrödinger equation corresponding to electronic wave functions.

In addition, the consideration of the Born model in order to describe the interaction of two isolated atoms constitutes an important fact. This model has been applied the last twenty years with limited success.

REFERENCES

- 1. P.W. Anderson. Phys. Rev. Lett. 21 (1968), 13.
- 2. P.W. Anderson. Phys. Rev. 181 (1969), 25.
- 3. D.W. Bullett. AIP Conf. Proc. nº 20 (1974), 139-144.
- 4. J.D. Joannopoulos, M.L. Cohen. AIP Conf. Proc. nº 20 (1974), 85-89.
- 5. J.D. Joannopoulos, F. Ynduráin. Phys. Rev. B 10 (1974), 5164.
- J. Avendaño, F.L. Castillo-Alvarado, R.A. Barrio. J. Non-Cryst. Solids 137-138 (1991), 299-302.
- 7. K. Pierz, W. Fuhs, H. Mell. Phil. Mag. B 63 (1991), 123.
- 8. M.F. Thorpe. AIP Conf. Proc. nº 20 (1974), 267-273.
- 9. R. Alben. AIP Conf. Proc. nº 20 (1974), 255.
- 10. R. Haydock, V. Heine, M.J. Kelly. J. Phys. C 5 (1972), 2845.
- 11. M.A. Grado, M. Grado: "A new mathematical model for cluster calculation in tetrahedrally bonded amorphous semiconductors." Act. Pass. Electronic Comp., in press, (1993).





Rotating Machinery

Hindawi



Journal of Sensors



International Journal of Distributed Sensor Networks





Journal of Electrical and Computer Engineering



Advances in OptoElectronics

Advances in Civil Engineering

> Submit your manuscripts at http://www.hindawi.com









International Journal of Chemical Engineering



VLSI Design

International Journal of Antennas and Propagation



Active and Passive Electronic Components



Shock and Vibration



Advances in Acoustics and Vibration